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DATE: August 16, 2001

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

|              |                                       |                 |            |
|--------------|---------------------------------------|-----------------|------------|
| Applicant:   | Galen R. Hatfield                     | Group Art Unit: | 2881       |
| Serial No.:  | 09/268,892                            | Examiner:       | K. Nguyen  |
| Filing Date: | March 16, 1999                        | Docket No.:     | D-43025-01 |
| Title:       | AUTHENTICATION SYSTEM AND METHODOLOGY |                 |            |

Assistant Commissioner for Patents  
Washington, D.C. 20231

RESPONSE

In response to the Office Action mailed April 16, 2001, the period for response having been extended until August 16, 2001 by the enclosed Petition for Extension of Time, please amend the above-identified application as noted below and consider the remarks that follow.

In the Drawings:

Please add the attached drawing of Fig. 2.

In the Specification:

Please add the following paragraph at page 7 before the title "Detailed Description of Illustrative Embodiments":

-- Figure 2 is a perspective view of a package 10 according to the present invention comprising a product 12 and a packaging polymeric film 14 incorporating an authenticating agent. --

In the Claims:

Please cancel claims 11-12 and 16.

Please amend claims 1, 7, 13-15, and 17-20 as follows:

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1. (Amended) A package comprising a product and an effective amount of authenticating agent incorporated into the package, wherein the authenticating agent is a substance that forms detectable free radicals upon irradiation.